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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
09/942,718	08/31/2001	Masataka Shirai	NIT-302	8857	
75	90 09/25/2003				
Mattingly, Stanger & Malur, P.C			EXAMINER		
Suite 370 1800 Diagonal Road			FLORES RUIZ, DELMA R		
Alexandria, VA	22314		ART UNIT	PAPER NUMBER	
			2828		
			DATE MAILED: 09/25/2003	DATE MAILED: 09/25/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	V
	09/942,718	SHIRAI ET AL.	
Office Action Summary	Examiner	Art Unit	
	Delma R. Flores Ruiz	2828	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with	n the correspondence addres	s
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	66(a). In no event, however, may a rep within the statutory minimum of thirty ill apply and will expire SIX (6) MONT cause the application to become ABA	oly be timely filed (30) days will be considered timely. HS from the mailing date of this community. NDONED (35 U.S.C. § 133).	nication.
1) Responsive to communication(s) filed on 06 A	<u>lugust 2003</u> .		
2a) This action is FINAL . 2b)⊠ Thi	s action is non-final.		
3) Since this application is in condition for allowa			erits is
closed in accordance with the practice under a Disposition of Claims	Ex paπe Quayle, 1935 C.D	. 11, 453 O.G. 213.	
4) \boxtimes Claim(s) <u>1 – 3, 5 – 7, and 9 – 13</u> is/are pendir	ng in the application.		
4a) Of the above claim(s) is/are withdraw	vn from consideration.		
5) Claim(s) is/are allowed.	·	0 0 00	
6) Claim(s) $1-3$, $5-7$, and $9-13$ is/are rejected	d.	Paul Do	
7) Claim(s) is/are objected to.		PAUL IP	
8) Claim(s) are subject to restriction and/or Application Papers	election requirement.	SUPERVISORY PATENT EXAM TECHNOLOGY CENTER 28	
9) The specification is objected to by the Examiner	·.		
10) The drawing(s) filed on is/are: a) accep	ted or b) objected to by the	e Examiner.	
Applicant may not request that any objection to the			-
11)☐ The proposed drawing correction filed on		sapproved by the Examiner.	
If approved, corrected drawings are required in rep			
12) The oath or declaration is objected to by the Exa	aminer.		
Priority under 35 U.S.C. §§ 119 and 120		440() () = (0	
13) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. §	119(a)-(d) or (t).	
a) All b) Some * c) None of:	. have been received		
1. Certified copies of the priority documents		nlication No	
2. Certified copies of the priority documents	•	•	
 3. Copies of the certified copies of the prior application from the International Bur * See the attached detailed Office action for a list of the prior action f	eau (PCT Rule 17.2(a)).		l e
14) Acknowledgment is made of a claim for domestic	priority under 35 U.S.C. §	119(e) (to a provisional app	lication).
 a) ☐ The translation of the foreign language prof 15)☐ Acknowledgment is made of a claim for domestic 	•		
Attachment(s)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of In	ummary (PTO-413) Paper No(s) formal Patent Application (PTO-152	2)
C. D. M. A. J. J. J. Office			

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-3, 5-7, 9-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tohyama et al (5,642,371) in view of Okumura (6,377,597)

Regarding claim 1, Tohyama discloses a module for optical communication having modulator integrated laser includes a semiconductor laser active (see Figs. 16 – 18, Character 55, Column 14, lines 57 – 67, Column 15, lines 1 – 6) and, an optical modulation region (Column 13, lines 4 – 11, Column 20, lines 23 – 34) for modulating the light from the semiconductor laser active region and a temperature control region (see Figs. 16 – 18, Character 70, Column 2, lines 27 – 37, Column 3, lines 5 – 67, Column 10, lines 6 – 17, Column 15, lines 39 – 49) for controlling temperature of at least the optical modulation region, said semiconductor laser active region having a

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multiple quantum well structure (see Figs. 16 – 18, Character 55 and 53), wherein a semiconductor laser active region or temperature of a component in thermal contact with the semiconductor laser active region for holding the temperature of the semiconductor laser active region is set to 35° C or higher during operation of the semiconductor laser active region and the optical modulation region (see Fig. 28). Tohyama discloses the claimed invention except for multiple quantum well having at least two quaternary mixed crystal layers in which a band offset of conduction band is larger than a band offset of a valence electron band, said at least two quaternary mixed crystal layers being selected from the group consisting of quaternary mixed compound of In. Ga. Al and As and a quaternary mixed compound of Un, Ga, N and As. It would have been obvious at the time of applicant's invention, to combine Okumura of teaching a multiple quantum well having at least two quaternary mixed crystal layers in which a band offset of conduction band is larger than a band offset of a valence electron band, said at least two quaternary mixed crystal layers being selected from the group consisting of quaternary mixed compound of In, Ga, Al and As and a quaternary mixed compound of Un. Ga. N and As with a module device because it would have been obvious to one having ordinary skill in the art at the time the invention was made to multiple quantum well having at least two quaternary mixed crystal layers in which a band offset of conduction band is larger than a band offset of a valence electron band, said at least two quaternary mixed crystal layers being selected from the group consisting of quaternary mixed compound of In, Ga, Al and As and a quaternary mixed

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compound of Un, Ga, N and As, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. In re Leshin, 125 USPQ 416.

Regarding claims 2 – 3 Tohyama disloses the temperature control component is a heating component or a heater and the control temperature control component is disposed without having a cooling component (see Figs. 16 – 18, Character 70, Column 2, lines 27 – 37, Column 3, lines 5 – 67, Column 10, lines 6 – 17, Column 15, lines 39 – 49).

Regarding claims 5 and 11, Tohyama discloses a module for optical communication and optical transmission module having a modulator-integrated laser includes a semiconductor laser active (see Figs. 16 – 18, Character 55, Column 14, lines 57 – 67, Column 15, lines 1 – 6), having at least two active regions, (see Figs. 16 – 18, Character 53 and 55) and an optical modulation region (Column 13, lines 4 – 11, Column 20, lines 23 – 34) for modulating the light from the semiconductor laser active region and a temperature control region (see Figs. 16 – 18, Character 70, Column 2, lines 27 – 37, Column 3, lines 5 – 67, Column 10, lines 6 – 17, Column 15, lines 39 – 49) for the temperature control at least the optical modulation region, said semiconductor laser active region having a multiple quantum well structure (see Figs. 16 – 18, Character 55 and 53), wherein a temperature of at least the semiconductor

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laser active region or semiconductor laser active region for holding the temperature of the semiconductor laser active region set to 35 C or higher during operation of the semiconductor laser active region and the optical modulation region (See Fig. 28). Tohyama discloses the claimed invention except for multiple quantum well having at least two quaternary mixed crystal layers in which a band offset of conduction band is larger than a band offset of a valence electron band, said at least two quaternary mixed crystal layers being selected from the group consisting of quaternary mixed compound of In, Ga, Al and As and a quaternary mixed compound of Un, Ga, N and As. It would have been obvious at the time of applicant's invention, to combine Okumura of teaching a multiple quantum well having at least two quaternary mixed crystal layers in which a band offset of conduction band is larger than a band offset of a valence electron band, said at least two quaternary mixed crystal layers being selected from the group consisting of quaternary mixed compound of In, Ga, Al and As and a quaternary mixed compound of Un, Ga, N and As with a module device because it would have been obvious to one having ordinary skill in the art at the time the invention was made to multiple quantum well having at least two quaternary mixed crystal layers in which a band offset of conduction band is larger than a band offset of a valence electron band, said at least two quaternary mixed crystal layers being selected from the group consisting of quaternary mixed compound of In, Ga, Al and As and a quaternary mixed compound of Un, Ga, N and As, since it has been held to be within the general skill of a

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worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. In re Leshin, 125 USPQ 416.

Regarding claims 6 – 7 and 12 – 13, Tohyama disclose the temperature control component is a heating component or a heater and the control temperature control component is disposed without having a cooling component (see Figs. 16 – 18, Character 70, Column 2, lines 27 – 37, Column 3, lines 5 – 67, Column 10, lines 6 – 17, Column 15, lines 39 – 49).

Regarding claims 9 and 10 Tohyama disclose the semiconductor laser chip region and the optical modulation region are constituted, respectively, with semiconductor chip regions separately from each other and are constituted as semiconductor chip region integrated in one identical substrate (see Figs 16 – 18).

Response to Arguments

Applicant's arguments filed 8/6/2003 have been fully considered but they are not persuasive. Applicant's arguments with respect to claims 1 - 3, 5 - 7, and 9 - 13 have been considered but are most in view of the new ground(s) of rejection.

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Delma R. Flores Ruiz whose telephone number is (703) 308-6238. The examiner can normally be reached on M - F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Paul Ip can be reached on (703) 308-3098. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 306-3431.

Examiner
Art Unit 2828

DRFR/PI

September 5, 2003

Paul Ip Supervisor Patent Examiner Art Unit 2828